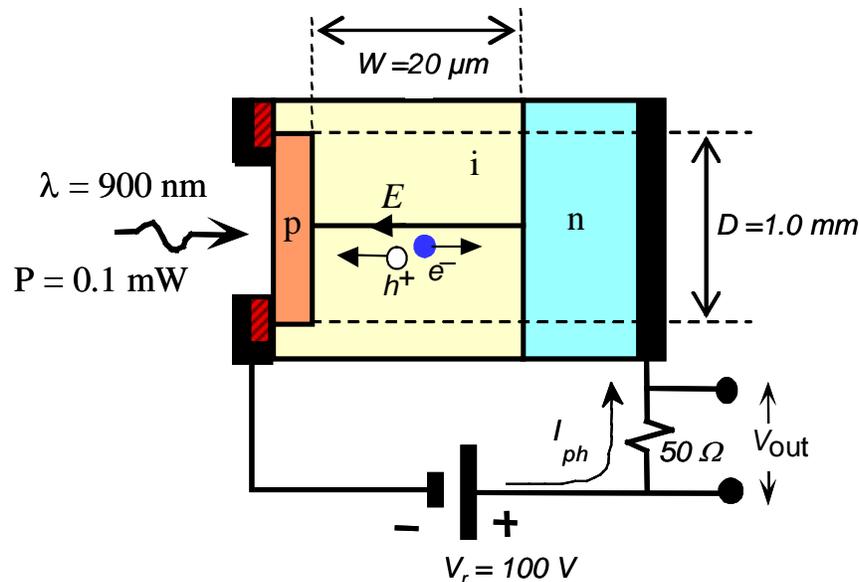


OPTI 500D, HOMEWORK #2

Due February 20, 2012

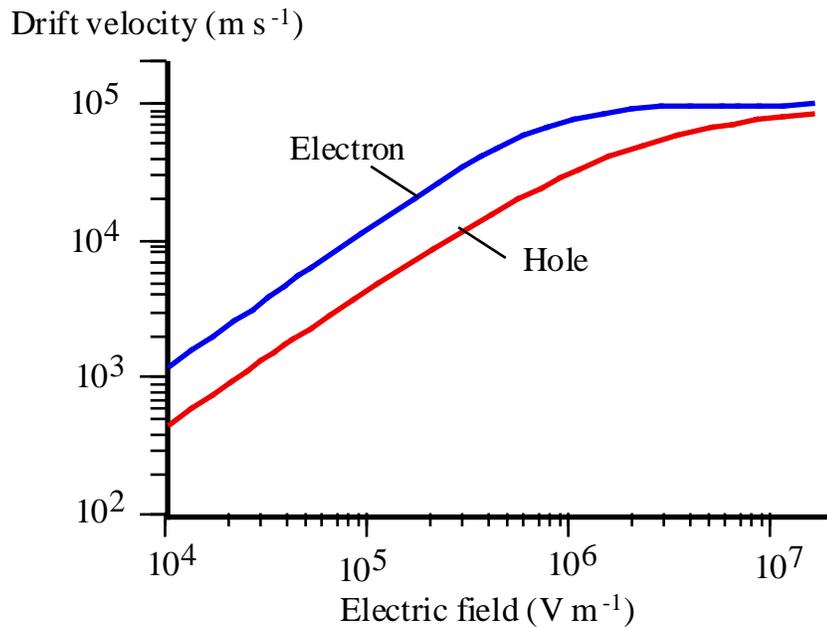


1. The p-i-n photodiode shown above is fabricated from n-type, p-type and i-type (undoped) silicon. The front surface has been anti-reflection coated so that all incident light enters the semiconductor. The absorption coefficient for silicon is approximately 300 cm^{-1} for light with a wavelength of 900 nm. The n-type layer is 0.1 microns thick – sufficiently thin so that light absorption is negligible for this layer. Calculate the quantum efficiency for the photodiode at 900 nm, assuming the any light that passes through the i-layer into the p-layer is lost and does not contribute to photocurrent.
2. Find the responsivity for the photodiode at 900 nm in units of Amps/Watt. (Planck's constant is $h = 6.6261 \times 10^{-34} \text{ J s}$).
3. Find the voltage across the external 50-ohm load if the optical power on the photodiode is 0.1 mW at a wavelength of 900 nm.
4. The photodiode has a reverse bias of 100 volts that appears entirely across the undoped i-layer of width 20 microns. Find the transit time for an electron, and for a hole, across the entire 20-micron length of the i-layer, using the drift velocity curves below.
5. The photodiode has a diameter of 1.0-mm.
 - a. Find its capacitance.

For this calculation, use a simple model for the photodiode. Treat the p-i-n structure as if it were equivalent to a parallel metal plate capacitor, with the plates separated by 20 microns

and the gap between the plates filled with silicon, a material that has a dielectric constant of 11.9. Parallel plates have a capacitance $Ak\epsilon_0/w$, where A is area of the plates, k is the dielectric constant of the material between the plates, $\epsilon_0 = 8.8542 \times 10^{-14}$ F/cm is the permittivity of free space, and w is the plate separation.

- b. Neglecting any “parasitic” resistance or capacitance, find the RC time constant for the photodiode circuit.



Drift velocity vs. electric field for holes and electrons in Si.

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